




<p>Searched</p> 	<p>Application/Control No.</p> <p>10684986</p>	<p>Applicant(s)/Patent Under Reexamination</p> <p>LAKE, JOHN M.</p>
	<p>Examiner</p> <p>Duong, Oanh</p>	<p>Art Unit</p> <p>2155</p>

Class	SubClass	Date	Examiner
709	203-206, 217, 219, 223, 224,245	10/29/2006	o.d
707	3, 10	10/29/2006	o.d

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Search Notes 	Application/Control No. 10684986	Applicant(s)/Patent Under Reexamination LAKE, JOHN M.
	Examiner Duong, Oanh	Art Unit 2155

Notes	Date	Examiner
EAST text search of USPAT, JPO, EPO, DERWENT, IBM_TDB, US-PGPUB.Search NPL using DialogLink	10/29/2006	o.d
Concultaed with Primary Philip Tran about allowability	10/29/2006	o.d
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see attached

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